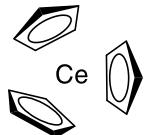


Catalog # 58-7500 Tris(cyclopentadienyl)cerium(III) (99.9%-Ce) (REO)

**Thermal Behavior:**

- Sublimation at 210-235°C/1 mTorr [1, 2]
- Melting point 435°C [1, 2]

Technical Notes:

1. MOCVD, ALD precursor for preparation of cerium containing thin films

| Target Deposit | Deposition Technique | Delivery Temperature | Pressure | Co-reactants | Deposition Temperature | Ref. |
|------------------------------------|----------------------|----------------------|-----------|--|------------------------|------|
| SrS-Ce ₂ S ₃ | ALD | 180°C | 240 mTorr | Sr(tmhd) ₂ , H ₂ S | 380°C | 3 |

References:

1. [*J. Am. Chem. Soc.* **1956**, *78*, 42.](#)
2. [*Polyhedron* **1983**, *2*, 969.](#)
3. [*J. Electrochem. Soc.*, **2001**, *148*, C427.](#)